



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

September 24, 2025

IGI Report Number

LG734518087

Description

LABORATORY GROWN DIAMOND

Shape and Cutting Style

MARQUISE BRILLIANT

Measurements

11.79 X 6.59 X 4.20 MM

GRADING RESULTS

Carat Weight

2.02 CARATS

Color Grade

D

Clarity Grade

VVS 1

ADDITIONAL GRADING INFORMATION

Polish

EXCELLENT

Symmetry

EXCELLENT

Fluorescence

NONE

Inscription(s)

 LG734518087

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.
Type IIa

Report verification at igi.org

PROPORTIONS

Thick To Very Thick (Faceted)

16.5%

40%

56%

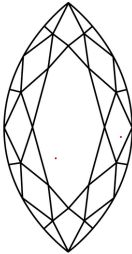
63.7%

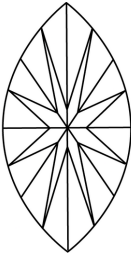
Pointed



Sample Image Used

CLARITY CHARACTERISTICS





KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

IF VVS ¹⁻² VS ¹⁻² SI ¹⁻² I ¹⁻³

Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

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